

where  $\Gamma(x)$  is the Gamma function, defined as [715]:

$$\Gamma(x) = \int_0^{\infty} e^{-y} y^{x-1} dy$$

The mean,  $E(x)$ , and variance,  $\sigma^2(x)$ , of  $x$  are given by:

$$E(x) = Ad \quad (3.10)$$

$$\sigma^2(x) = Ad(1 + Ad/\alpha) \quad (3.11)$$

The values of  $E(x)$  and  $\sigma^2(x)$  for the number of defects on a chip are obtained either from experimental measurements or by process simulation [167, 710]. Substitution in the above equations then leads to the determination of yield parameters,  $d$  and  $\alpha$ . The yield is obtained as the probability,  $p(0)$ , of no defect on a chip. Thus, substituting  $x = 0$  in Equation 3.9, we get:

$$Y = (1 + Ad/\alpha)^{-\alpha} \quad (3.12)$$

When  $\alpha \rightarrow \infty$ , Equation 3.9 gives the *Poisson density function* with mean  $Ad$ , which corresponds to the unclustered distribution of defects (Figure 3.4(a)):

$$\text{For unclustered defects: } p(x) = \frac{(Ad)^x e^{-Ad}}{x!} \quad (3.13)$$

On substituting  $x = 0$  this gives the yield, which can also be obtained by substituting  $\alpha = \infty$  in Equation 3.12, as

$$Y_{\text{Poisson}} = e^{-Ad} \quad (3.14)$$

Equation 3.14 gives very low yields. For example, if the average number of defects is  $Ad = 1.0$  and  $\alpha = 0.5$ , which are quite typical for a large VLSI chip, then  $Y_{\text{Poisson}} = 1/e = 0.37$ . A yield of 37% is considered to be too low for a profitable manufacturing. A more realistic yield, which characterizes a mature process, is obtained from Equation 3.12 as 58%.

When the processing of a newly designed chip is first started, the yield may be low. It may even conform to the prediction of Equation 3.14. The diagnosis of defects leads to process improvements to a stage where no further improvement is possible. The resulting process, called *matured*, has significantly higher yield as compared to the new process yield.

**Example 3.5** *Cost of testability overhead.* Consider a VLSI manufacturing process characterized by: defect density,  $d = 1.25$  defects/cm<sup>2</sup>, and clustering parameter,  $\alpha = 0.5$ . The area of a chip is  $A = 8 \text{ mm} \times 8 \text{ mm} = 0.64 \text{ cm}^2$ . Equation 3.12 gives the yield as:

$$Y = \left(1 + \frac{0.64 \times 1.25}{0.5}\right)^{-0.5} = 0.62$$